

<b>Form PTO/SB/08A (Modified)</b>  <b>Information Disclosure Statement By Applicant</b>  <i>Page 1 of 6</i> <i>(Use as many sheets as necessary)</i>	<b>Att. Docket No.:</b> 008716 YSA/CPS/IBSS/LAP		<b>Application No.:</b> 10/691,418
	<b>Applicant:</b> Lin et al.		
	<b>Filing Date:</b> October 22, 2003		<b>Group:</b> 1794
	<b>U.S. Patent Documents</b>		

Examiner Initials*	Cite No.	Document Number	Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code			
		2,705,500	04-05-55	Deer	
		3,117,883	01-14-64	Pierett	
		3,457,151	10-27-66	Kortejarvi	
		3,522,083	07-19-70	Woolman	
		3,565,771	02-19-71	Gulla	
		3,679,460	07-25-72	Reid	
		4,100,252	07-11-78	Pitts	
		4,419,201	12-06-83	Levinstein et al.	
		<del>4,491,496</del>	<del>01-01-86</del>	<del>Esposito et al.</del>	
		4,673,554	06-16-87	Niwa et al.	
		4,713,119	12-15-87	Earhart et al.	
		<del>4,717,462</del>	<del>01-05-88</del>	<del>Homma et al.</del>	
		4,721,792	03-33-88	Fujiyama	
		4,756,322	07-12-88	Lami	
		4,959,105	09-25-90	Neidiffer et al.	
		<del>5,009,966</del>	<del>04-28-91</del>	<del>Sarg et al.</del>	
		5,032,469	07-16-91	Merz et al.	
		5,064,511	11-12-91	Gobbetti	
		5,104,501	04-14-92	Okabayashi	
		5,164,016	11-17-92	Henriet et al.	
		5,180,322	01-19-93	Yamamoto et al.	
		5,180,563	01-19-93	Lai et al.	
		5,202,008	04-13-93	Talieh	
		5,215,624	06-01-93	Dastolfo et al.	
		5,248,386	09-28-93	Dastolfo et al.	
		5,338,367	08-16-94	Henriet et al.	
		5,366,585	11-22-94	Robertson et al.	
		<del>5,401,936</del>	<del>06-21-95</del>	<del>Winn</del>	
		<del>5,401,940</del>	<del>09-28-95</del>	<del>Orabalogu et al.</del>	
		<del>5,474,640</del>	<del>12-12-95</del>	<del>Kane et al.</del>	

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	<b>U.S. Patent Documents</b>		

	5,509,558	04-23-96	Imai et al.	
	5,520,740	05-28-96	Kanai et al.	
	5,536,723	10-18-94	Kimoto et al.	
	<del>5,540,802</del>	<del>06-27-96</del>	<del>Goo</del>	
	<del>5,587,030</del>	<del>12-24-98</del>	<del>Colman et al.</del>	
	5,660,640	08-26-97	Laube	
	5,714,010	02-03-98	Matsuyama et al.	
	5,762,748	06-09-98	Banholzer et al.	
	5,808,270	09-15-98	Marantz et al.	
	5,840,434	11-24-98	Kojima et al.	
	<del>5,858,100</del>	<del>01-12-99</del>	<del>Moeda et al.</del>	
	<del>5,870,523</del>	<del>03-09-99</del>	<del>Wong et al.</del>	
	<del>5,888,438</del>	<del>05-14-99</del>	<del>Grimer et al.</del>	
	<del>5,910,238</del>	<del>06-08-99</del>	<del>Bowde et al.</del>	
	<del>5,916,278</del>	<del>06-29-99</del>	<del>Bailey et al.</del>	
	<del>5,916,454</del>	<del>06-30-99</del>	<del>Dierdorff et al.</del>	
	5,939,146	08-17-99	Lavernia	
	<del>5,963,827</del>	<del>09-21-99</del>	<del>Or et al.</del>	
	5,967,047	10-19-99	Agfa-Gevaert AG	
	<del>5,976,997</del>	<del>11-02-99</del>	<del>Tanaka</del>	
	<del>5,915,495</del>	<del>01-18-00</del>	<del>Khaladnikov et al.</del>	
	<del>5,951,114</del>	<del>01-18-00</del>	<del>Yee et al.</del>	
	<del>5,959,945</del>	<del>05-09-00</del>	<del>Crut et al.</del>	
	6,120,621	09-19-00	Jin et al.	
	6,120,640	09-19-02	Shih et al.	
	6,152,071	11-28-00	Akiyama et al.	
	6,306,489	10-23-01	Hellmann et al.	
	6,306,498	10-23-01	Quarzglas	
	6,338,906	01-15-02	Rittland et al.	
	6,379,575	04-30-02	Yin et al.	
	6,383,459	05-07-02	Singh et al.	
	6,394,023	05-28-02	Crocker	
	6,444,083	09-03-02	Steger et al.	

<b>Examiner:</b>	<b>Date Considered</b>

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	<b>U.S. Patent Documents</b>		

	6,454,870	09-24-02	Brooks	
	6,555,471	04-29-03	Sandhu et al.	
	6,565,984	05-20-03	Wu et al.	
	6,566,161	05-20-03	Rosenberg et al.	
	6,592,830	07-15-03	Krupin et al.	
	6,777,045	08-17-04	Lin et al.	
	6,902,627	06-07-05	Brueckner et al.	
	<del>6,988,938</del>	<del>06-07-05</del>	<del>Wang et al.</del>	
	6,933,025	08-23-05	Lin et al.	
	7,026,009	04-11-06	Lin et al.	
	US-2001-033706	10-25-01	Shimomura et al.	
	<del>US-2003-086448</del>	<del>07-04-02</del>	<del>Chang et al.</del>	
	US-2002-090464	07-11-02	Mingwei et al.	
	US-2003-047464	03-13-03	Sun et al.	
	US-2003-108680	06-12-03	Gell et al.	
	US-2003-116276	06-26-03	Weldon et al.	
	US-2003-118731	06-26-03	He et al.	
	US-2003-1364248	07-24-03	Krogh	
	US-2003-173526	09-18-03	Popiolkowski et al.	
	US-2003-170486	09-11-03	Austin et al.	
	<del>US-2003-185005</del>	<del>10-02-03</del>	<del>Lin et al.</del>	
	US-2003-196890	10-23-03	Le et al.	
	<del>US-2003-026017</del>	<del>08-06-03</del>	<del>Lin et al.</del>	
	US-2003-221702	12-04-03	Peebles	
	US-2004-045574	03-11-04	Tan	
	US-2004-0056211	03-25-04	Popiolkowski et al.	
	US-2004-0099285	05-27-04	Wang et al.	
	US-2004-0180158-A1	09/16/04	Lin et al.	
	US-2005-0028838-A1	02-10-05	Brueckner	
	US-2006-0105182-A1	05-18-06	Brueckner et al.	
	US-2006/0110620-A1	05-25-06	Lim et al.	

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### Foreign Patent or Published Foreign Patent Application

Examiner Initials*	Cite No.	Country Code-Number-Kind Code	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T
		DE-19719133-A1	11-12-98	Staudt	Abstract	
		EP-0239349	07-01-92	Murali		
		EP-0838838-A2	04-29-98	Kugo et al.		
		EP-0845545-A1	06-98	Ding et al.		
		EP-1049133-A2	11-02-00	Luscher et al.		
		EP-1158072-A2	11-28-01	Hirotake et al.		
		EP-1258908-A2	11-20-02	Lammert et al.		
		FR-2562097-A1	10-04-85	Krepler et al.	Translation	
		JP-02-101157	04-12-90	Fujikura Ltd.	Abstract	
		JP-03-138354	06-12-91	Osamu et al.	Abstract	
		JP-07-197272	08-01-95			
		JP-09-272965	10-21-97	Michio et al.	Abstract	
		JP-10-251871	09-22-98	Hong et al.	Abstract	
		JP-10-330971	12-15-98	Takeo et al.	Abstract	
		JP-10-045461	02-17-98	Yumiko et al.	Abstract	
		JP-11-137440	05-25-99		Abstract	
		JP-11-220164	08-10-99	Mitsuhiko et al.	Abstract	
		JP-11-283972	10-1599	Kazuhiro	Abstract	
		JP-11-345780	12-14-99	Kazuyoshi	Abstract	
		JP-11-59368	12-15-87	Kazuoki	Abstract	
		JP-2000-072529	03-07-00	Akira et al	Abstract	
		JP-2000-191370	07-11-00	Naomi et al.	Abstract	
		JP-2000-228398	10-15-99	Kazuhiro	Abstract	
		JP-2002-069695	03-08-02		Abstract	
		JP-2002-069695	03-08-02		Abstract	
		JP-2250990	10-08-99	Masahiro	Abstract	
		JP-54162696	12-24-79	Nagata Kazushi	Abstract	
		<del>JP-54162696</del>	<del>12-24-79</del>	<del>Nagata Kazushi</del>	<del>Abstract</del>	
		JP-63149396	06-22-98	Tanabe Makoto	Abstract	
		JP-63235435	09-30-88	Watanabe	Abstract	
		TW-546680	08-11-03	Hirose et al.	Abstract	
		WO-98/50599	11-12-98	Hellmann		
		<del>WO-98/50599</del>	<del>11-12-98</del>	<del>Hellmann</del>	<del></del>	
		WO-00/215255	02-21-02	Chem Trace Corp		
		WO-03/083160	10-09-03	Lin et al.		
		WO-06/073585	07-13-06	Lin et al.		

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